

LISTING AND AMENDMENT OF THE CLAIMS

1. (currently amended) Process for cathodically electrodepositing a selected metallic material on a permanent or temporary substrate in nanocrystalline form with an average grain size of less than 100 nm using ~~pulse~~ electrodeposition at a deposition rate of at least ~~0,05~~ 0.05 mm/h, comprising:

- (a) providing an aqueous electrolyte containing ions of said metallic material, and
- (b) agitating the electrolyte at an agitation rate of 0.01 to 10 liter/min/cm².

~~maintaining said electrolyte at a temperature in the range between 0 to 85°C, providing an anode and a cathode in contact with said electrolyte, passing single or multiple D.C. cathodic current pulses between said anode and said cathode at a cathodic current pulse frequency in a range of about 0 and 1000 Hz, at pulsed intervals during which said current passes for a t_{on} time period in the range of about 0,1 to 50 msec and does not pass for a t_{off} time period in the range of about 0 to 500 msec, and passing single or multiple D.C. anodic current pulses between said cathode and said anode at intervals during which said current passes for a t_{anodic} time period in the range of 0 to 50 msec, a duty cycle being in a range of 5 to 100% and a cathodic charge (Q_{cathodic}) per interval being always larger than a anodic charge (Q_{anodic}).~~

2. (currently amended) Process as claimed in claim 27 or 28, characterized in that single or multiple D.C. cathodic-current pulses between said anode and said cathode are present and have a peak current density in the range of about ~~0,01~~ 0.01 to 20 A/cm².

3. (currently amended) Process as claimed in claim 2, characterized in that the peak current density of the cathodic-current pulses is in the range of about ~~0,1~~ 0.1 to 20 A/cm², ~~preferably in the range of about 1 to 10 A/cm².~~

4. (currently amended) Process as claimed in ~~any of claims 1 to 3~~ claim 27 or 28, characterized in that said selected metallic material is (a) a pure metal or alloys of metals selected from the group consisting of Ag, Au, Cu, Co, Cr, Ni, Fe, Pb, Pd, ~~Rt~~Pt, Rh, Ru, Sn, V, W, Zn, or (b) an alloy containing at least one of the elements of group (a) and alloying elements selected from the group consisting of C, P, S and Si.

5. (currently amended) Process as claimed in ~~any of claims 1 to 4~~ claim 27 or 28, characterized in that the t_{on} -time period is in the range of about 1 to about 50 msec, the t_{off} -time period is in the range of about 1 to 100 msec and the t_{anodic} -time period is in the range of about 1 to 10 msec.

6. (currently amended) Process as claimed in ~~any of claims 1 to 5~~ claim 27 or 28, characterized in that the duty cycle ~~preferably~~ is in the range of 10 to 95 %, ~~and more preferably is in the range of 20 to 80 %.~~

7. (currently amended) Process as claimed in ~~any of claims 1 to 6~~ claim 27 or 28, characterized in that the cathodic-current pulse frequency ranges from 10 Hz to 350 Hz.

8. (currently amended). Process as claimed in ~~any of claims 1 to 7~~ Claim 1, characterized in that the deposition rate is ~~preferably~~ at least 0,075 0.075 mm/h ~~and more preferably at least 0,1 mm/h.~~

9. (currently amended) Process as claimed in ~~any of claims 1 to 9~~ Claim 1, characterized by agitating the electrolyte at an agitation rate in the range of ~~0 to 750~~ 1 to 500 ml/min/A, ~~preferably in a range of 0 to 500 ml/min/A.~~

10. (currently amended) Process as claimed in claim 9 1, characterized by agitating the electrolyte by means of pumps, stirrers or ultrasonic agitation.

11. (currently amended) Process as claimed in ~~any of claims 1 to 10~~ claim 27 or 28, characterized by a relative motion between anode and cathode.
12. (currently amended) Process as claimed in claim 11, characterized in that the speed of the relative motion between anode and cathode ranges from 0 to 600 m/min, ~~preferably from 0,003 to 10 m/min.~~
13. (original) Process as claimed in claim 11, characterized in that the relative motion is achieved by rotation of anode and cathode relative to each other.
14. (currently amended) Process as claimed in claim 13, characterized by a rotational speed of rotation of anode and cathode relative to each other ranging from ~~0,003~~ 0.003 to ~~0,15~~ 0.15 rpm ~~and preferably from 0,003 to 0,05 rpm.~~
15. (currently amended) Process as claimed in claim ~~11 or claim 12~~, characterized in that the relative motion is achieved by a mechanized motion generating a stroke of the anode and the cathode relative to each other.
16. (currently amended) Process as claimed in ~~claim 11 or 15~~ claim 11, characterized in that the anode is wrapped in an absorbent separator.
17. (currently amended) Process as claimed in ~~any of claims 1 to 16~~ claim 1, characterized in that said electrolyte contains a stress relieving agent or a grain refining agent selected from the group of saccharin, coumarin, sodium lauryl sulfate and thiourea.
18. (currently amended) Process as claimed in ~~any of claims 1 to 17~~ Claim 1, characterized in that said electrolyte contains particulate additives in suspension selected from pure metal powders, metal alloy powders or metal oxide powders of Al, Co, Cu, In, ~~NgMg~~, Ni, Si, Sn, V and Zn, nitrides of Al, B and Si, carbon C (~~graphite or diamond~~), carbides of B, Bi, Si,

W, or organic materials ~~such as PTFE and polymers spheres~~, whereby the electrodeposited metallic material contains at least 5 % of said particulate additives.

19. (original) Process as claimed in claim 18, characterized in that the electrodeposited metallic material contains at least 10 % of said particulate additives.

20. (original) Process as claimed in claim 18, characterized in that the electrodeposited metallic material contains at least 20 % of said particulate additives.

21. (original) Process as claimed in claim 18, characterized in that the electrodeposited metallic material contains at least 30 % of said particulate additives.

22. (original) Process as claimed in claim 18, characterized in that said electro deposited metallic material contains at least 40 % of said particulate additives.

23. (currently amended) Process as claimed in ~~any of claims 18 to 22~~ claim 18, characterized in that the particulate additives average particle size is below 10 μm , ~~preferably below 1000 nm, more preferably below 500 nm and most preferably below 100 nm.~~

24. (currently amended) Micro component produced by a ~~pulse~~ an electrodeposition process as claimed in claim 1, ~~especially produced by a pulse electrodeposition process as claimed in any of claims 1 to 22~~, having a maximum dimension of 1 mm, an average grain size equal to or smaller than 1000 nm, the ratio between the maximum dimension and the average grain size being greater than 10.

25. (original) Micro component as claimed in claim 24, characterized in that the ratio between the maximum dimension of the micro component and the average grain size is greater than 100.

26. (currently amended) Micro component as claimed in claim 24 ~~or 25~~, characterized by having a an equiaxed micro structure.

27. (new) Process according to Claim 1 characterized by:

- (a) providing an anode and a cathode in contact with said electrolyte,
- (b) passing single or multiple D.C. cathodic-current pulses between said anode and said cathode at a cathodic-current pulse frequency in a range of about 0 and 1000 Hz, at pulsed intervals during which said current passes for t_{on} -time period in the range of about 0.1 to 50 msec and does not pass for a t_{off} -time period in the range of about 0 to 500 msec,
- (c) Passing single or multiple D.C. anodic-current pulses between said cathode and said anode at intervals during which said current passes for a t_{anodic} -time period in the range of 0 to 50 msec,
- (d) a duty cycle being in a range of 5 to 100%; and
- (e) a cathodic charge ($Q_{cathodic}$) per interval being always larger than a anodic charge (Q_{anodic}).

28. (new) Process according to Claim 27, characterized by maintaining said electrolyte at a temperature in the range between 0 to 85°C.

29. (new) Process as claimed in claim 4, characterized in that said selected metallic material is a pure metal selected from the group consisting of Co and Ni, containing P.

30. (new) Process as claimed in claim 1, characterized in that said selected metallic material is an alloy of Fe with a pure metal selected from the group consisting of Co and Ni.